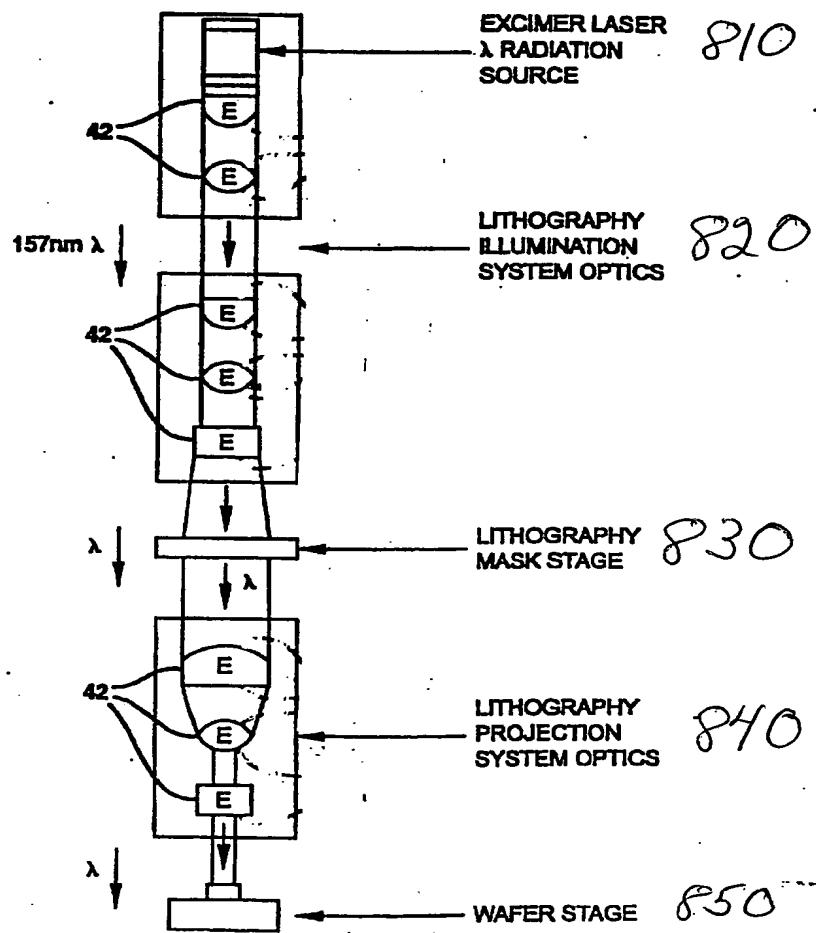
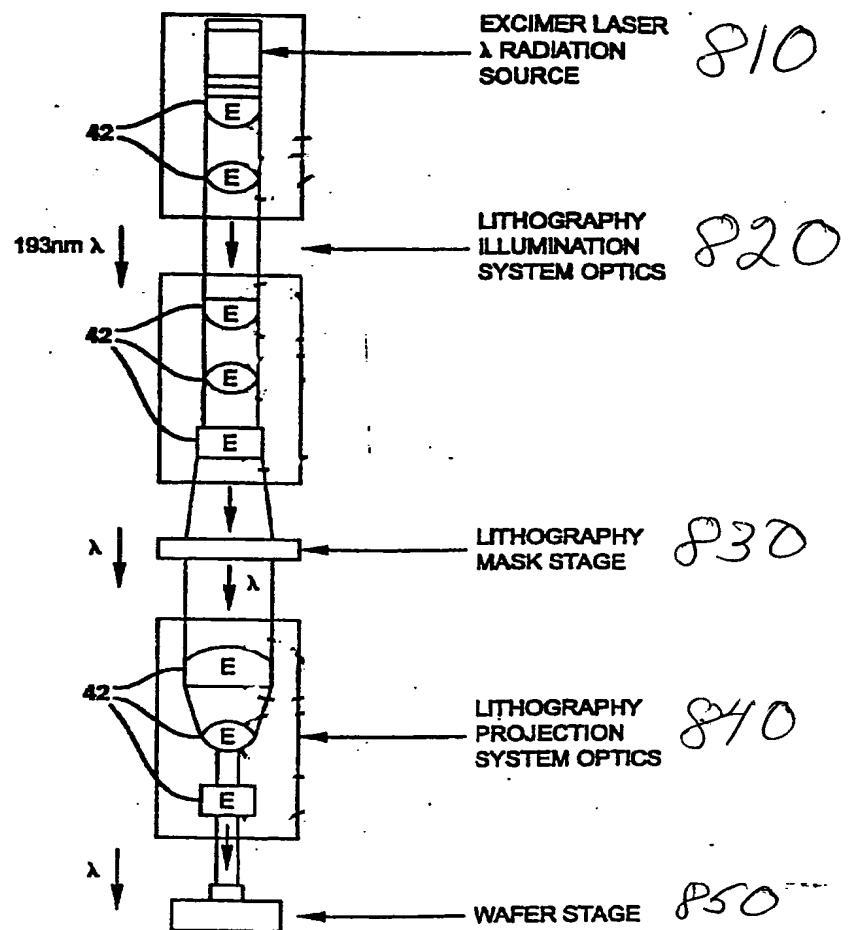


FIG 1



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FIG 2



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FIG. 3

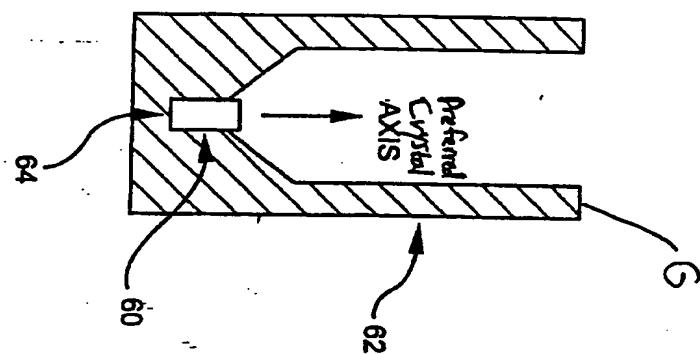
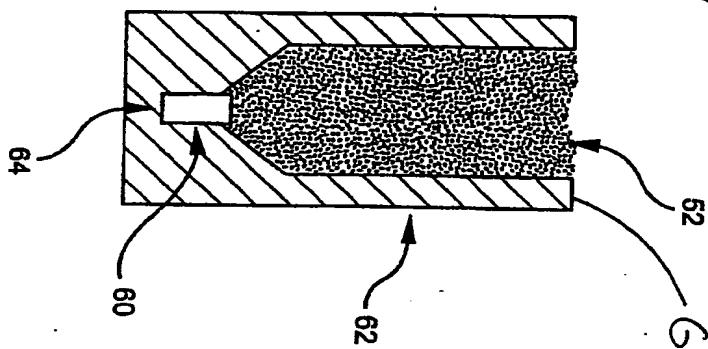


FIG. 4



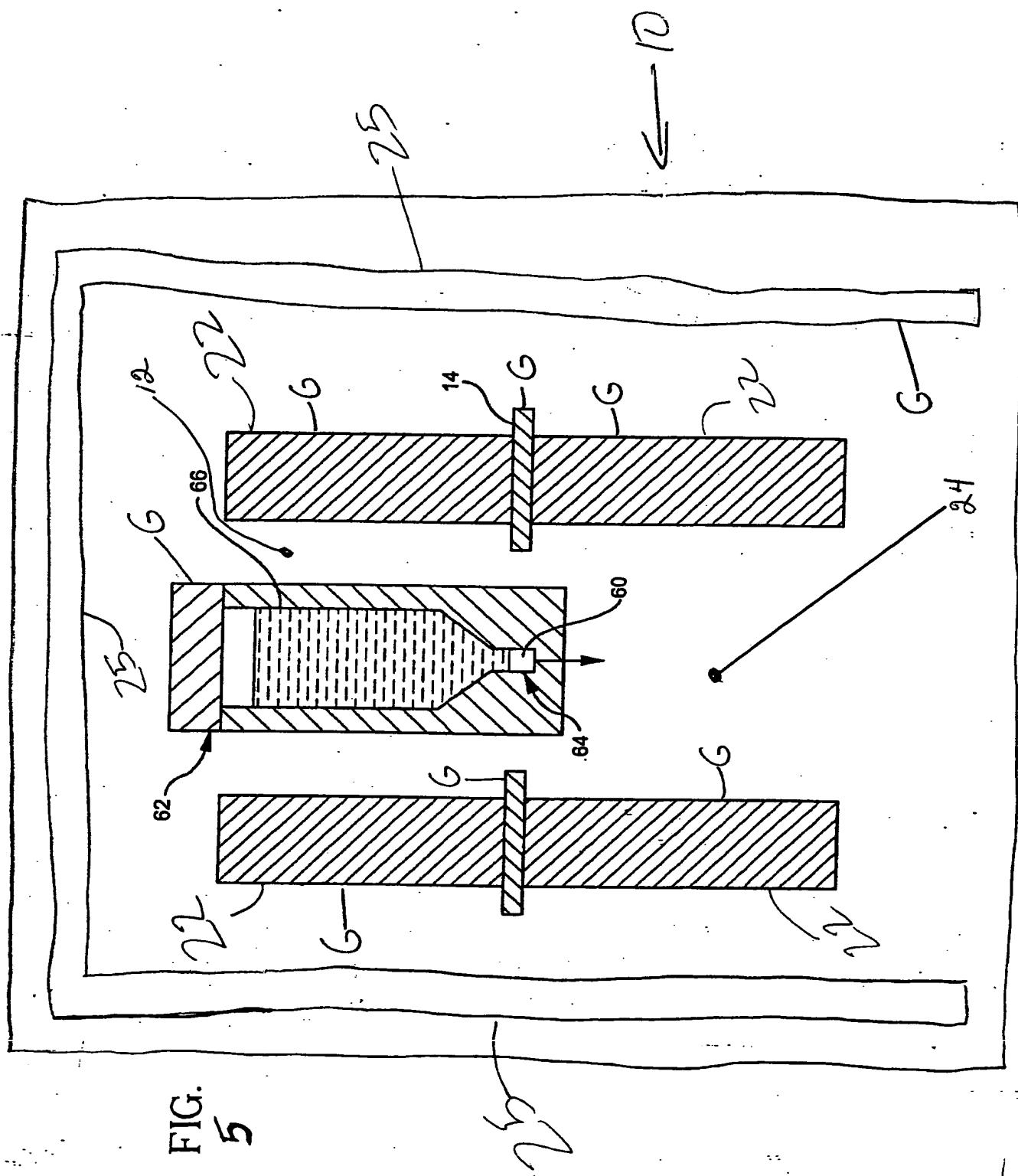


FIG.
5

FIG.
6

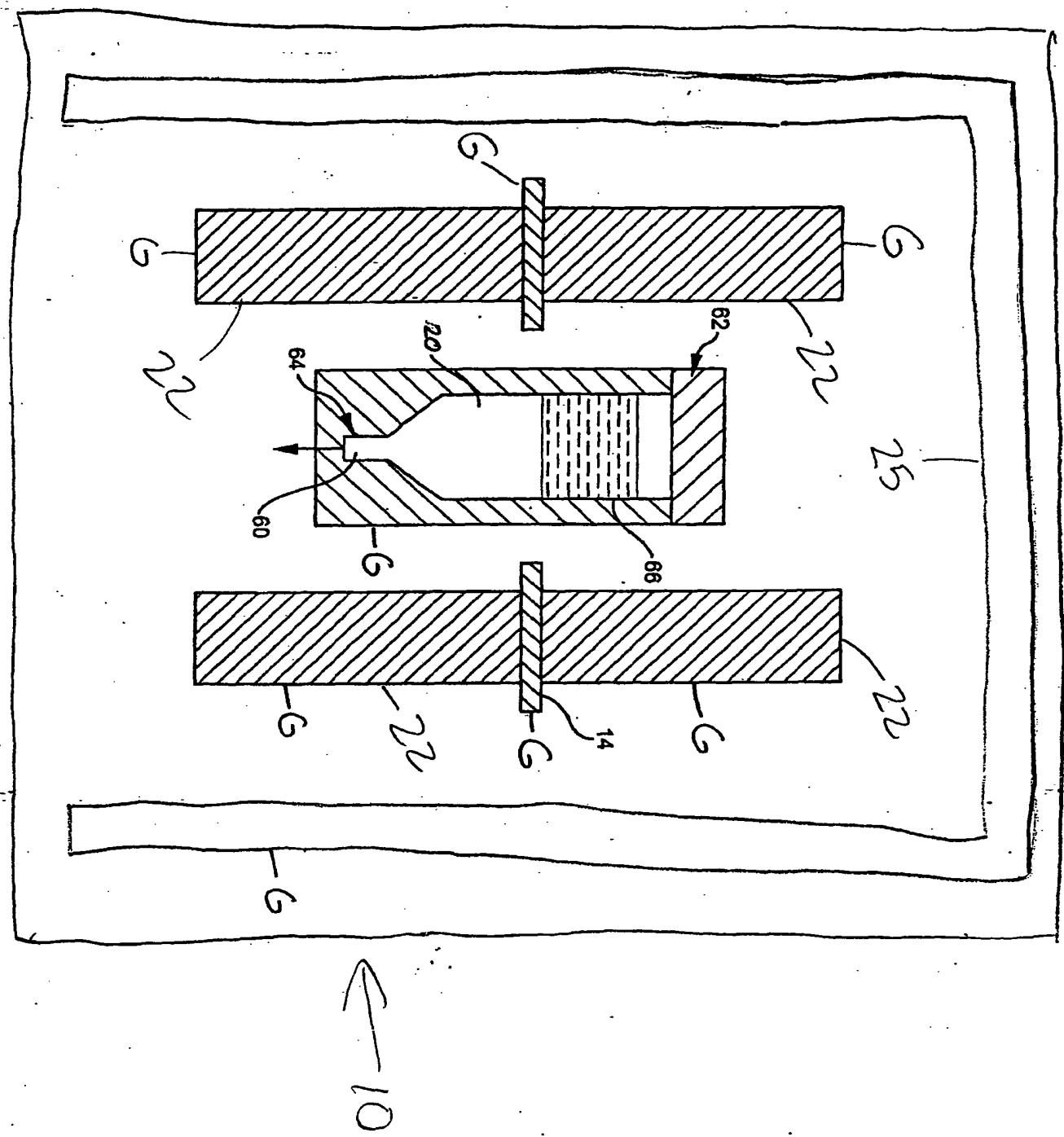
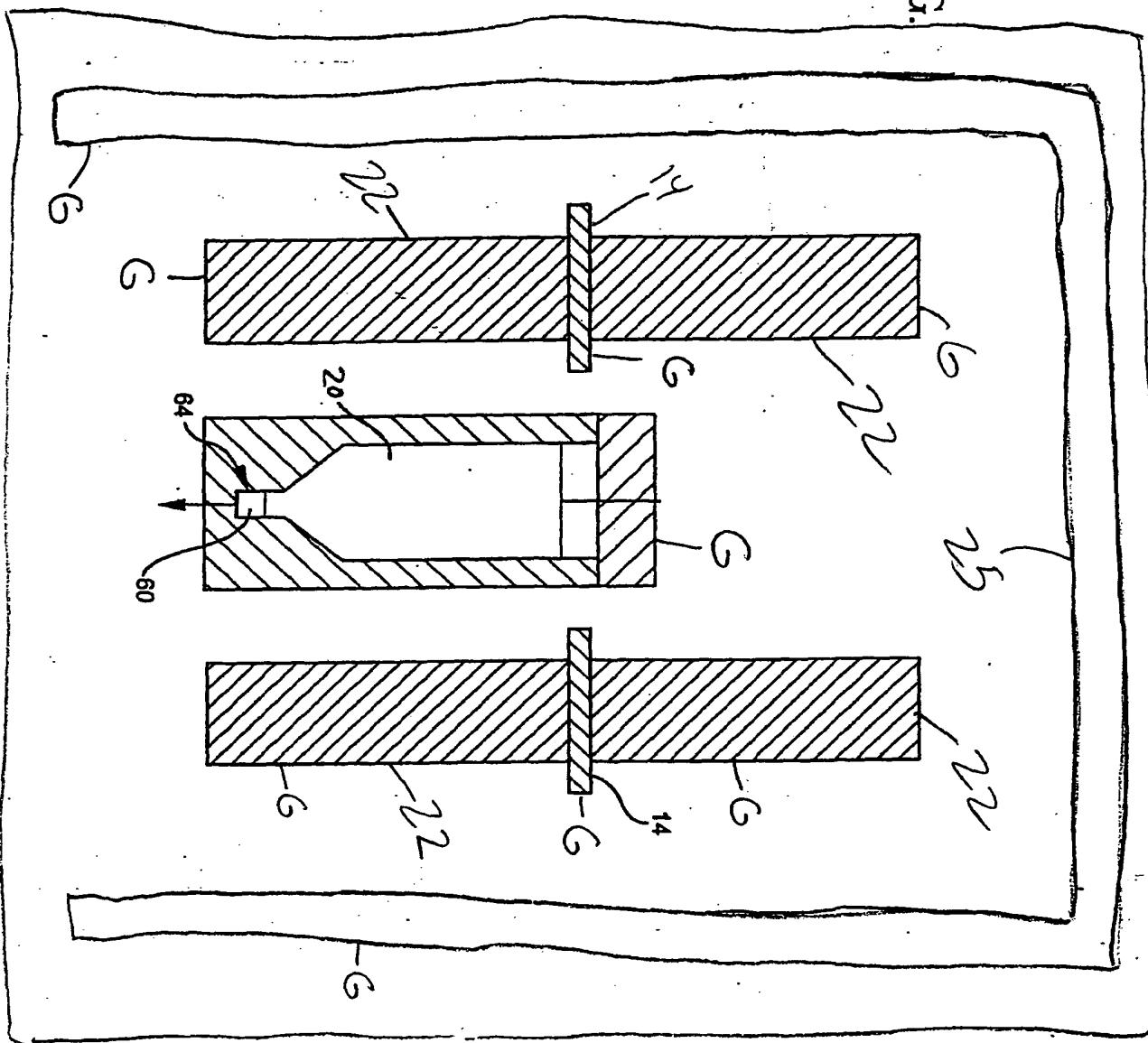


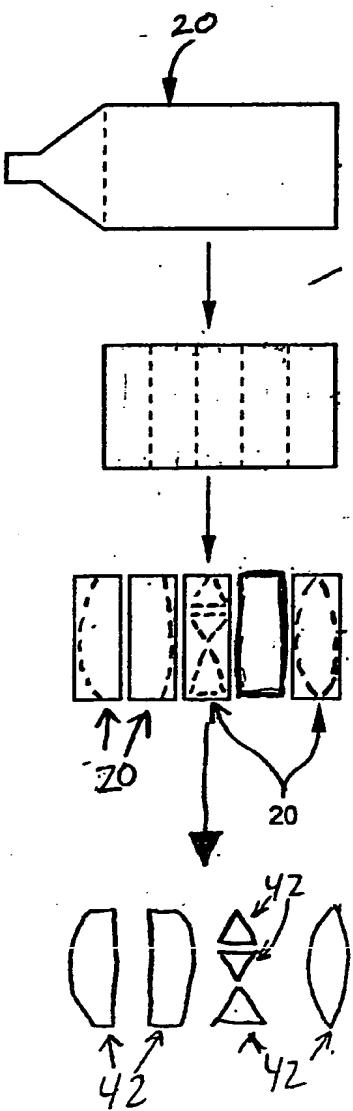
FIG.
7



← 10

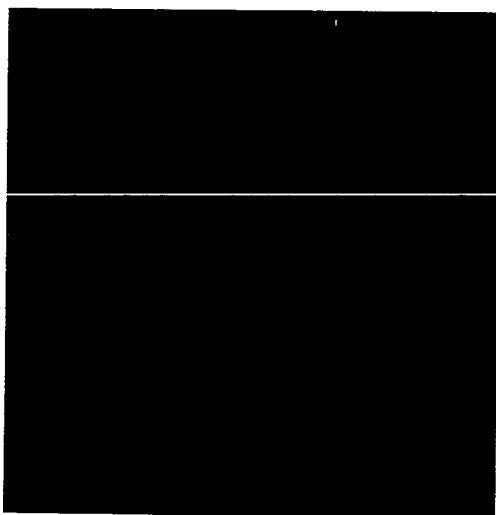
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FIG. 8

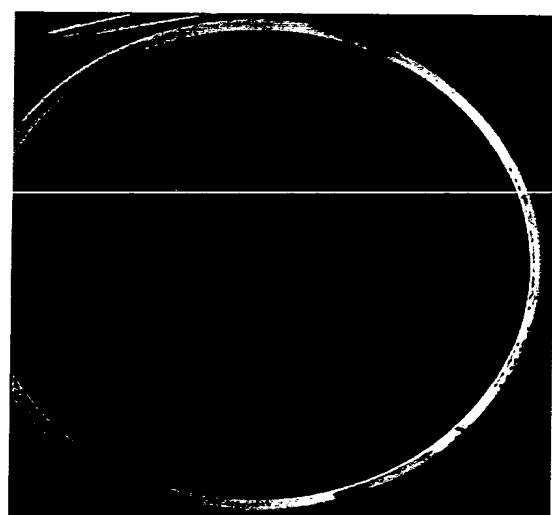


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• FIG. 9B

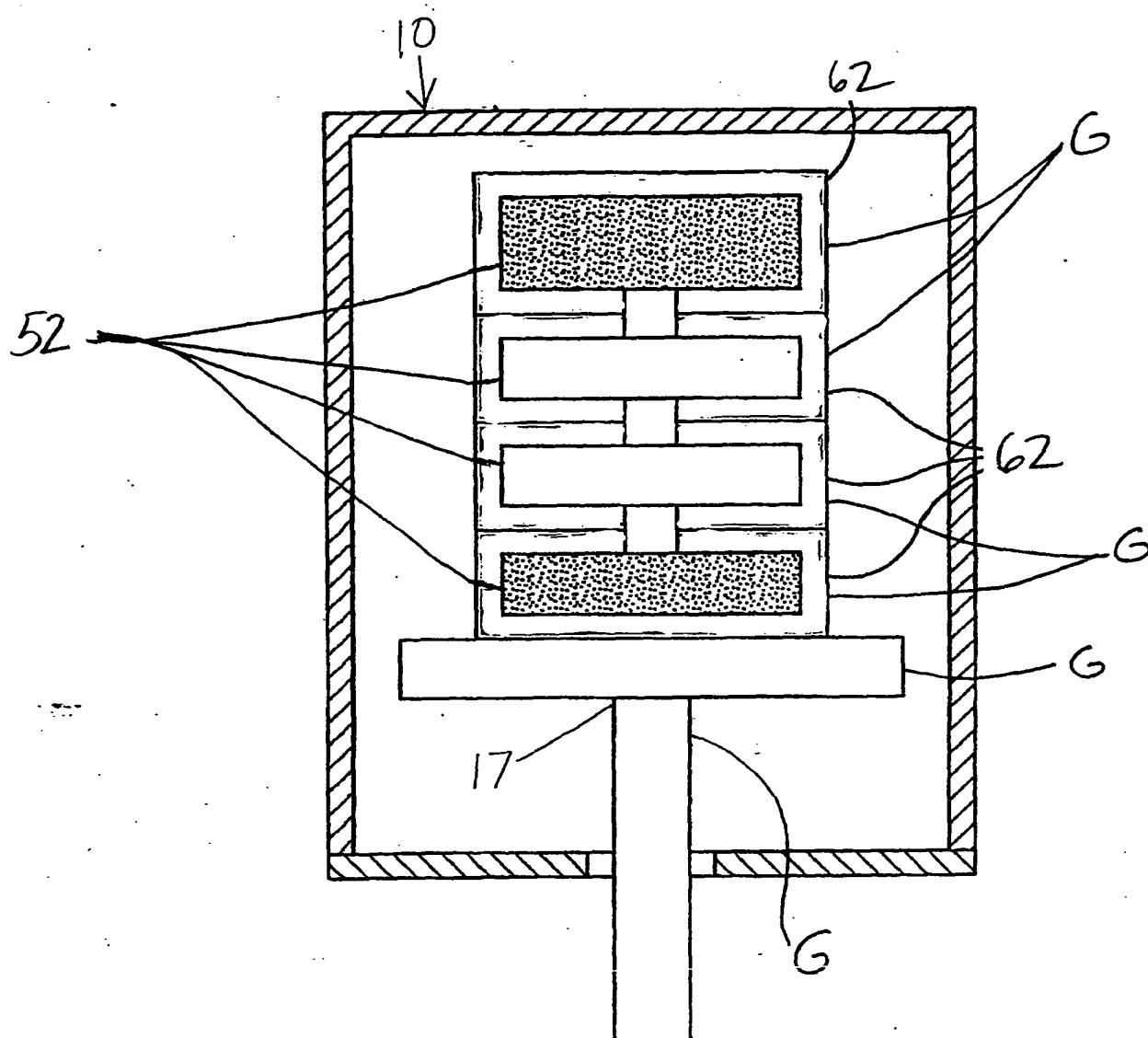


• FIG. 9A



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FIG. 10



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52

7/10

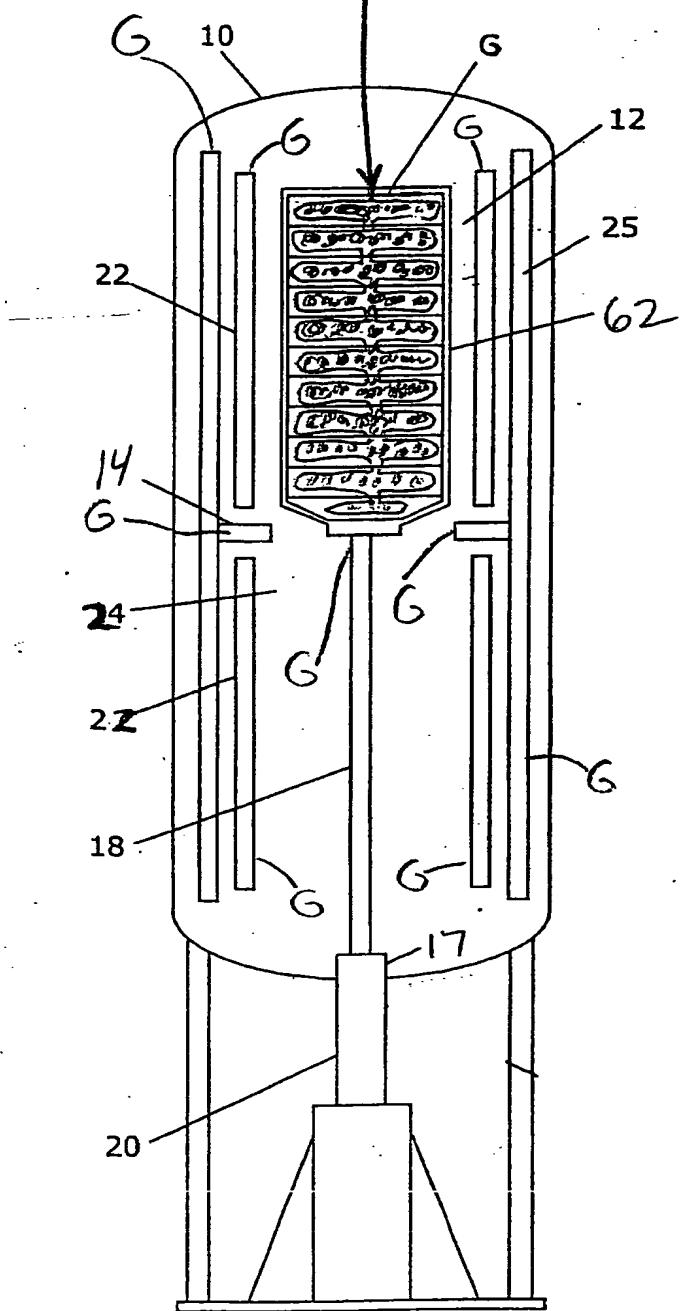


FIG. 11

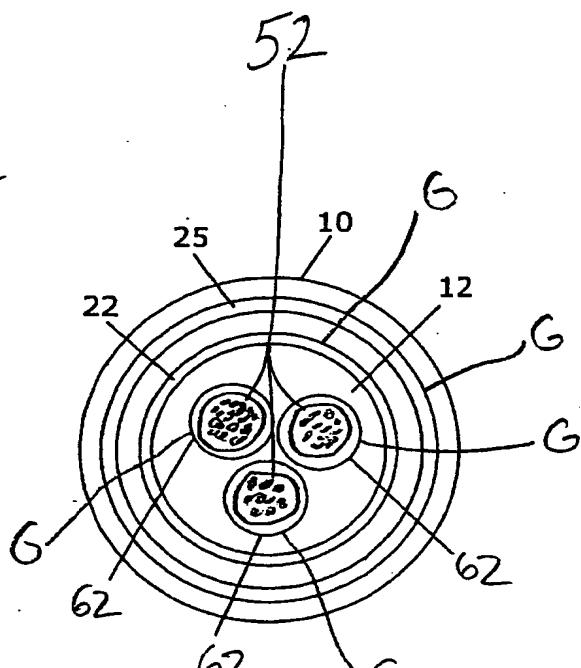
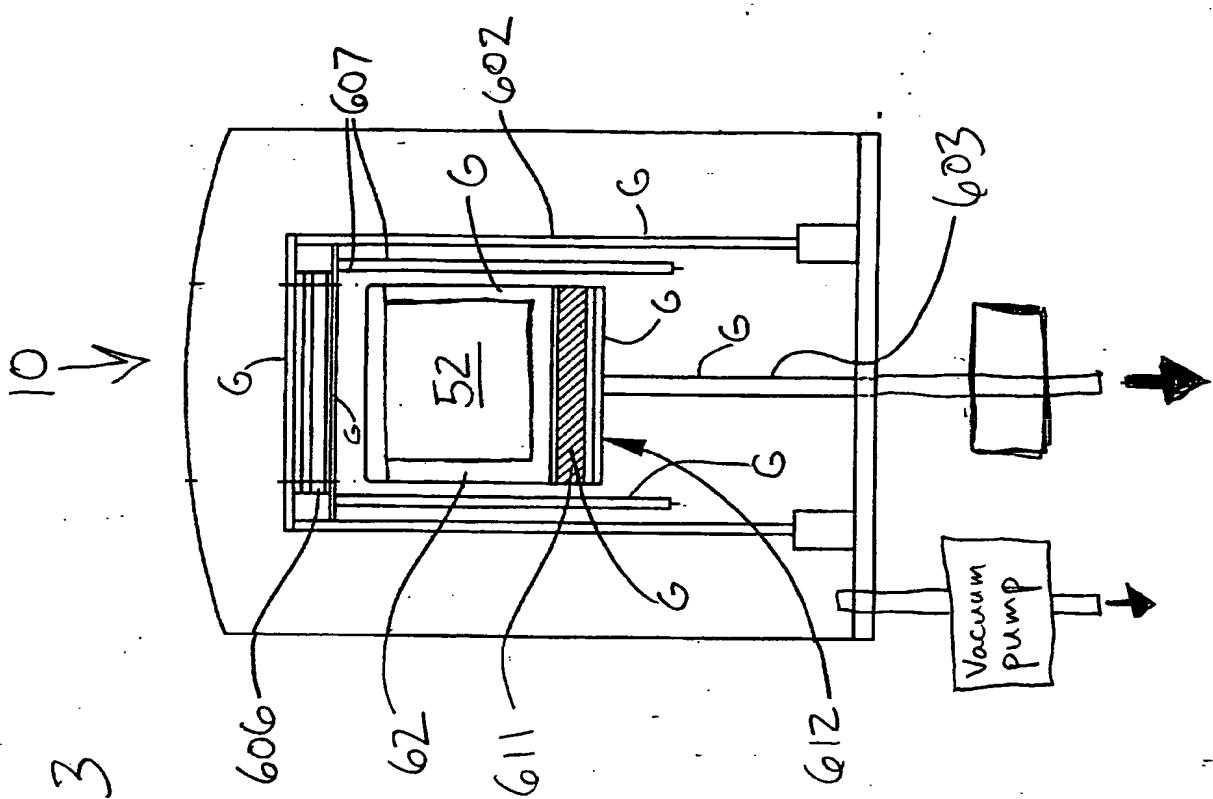


FIG. 12

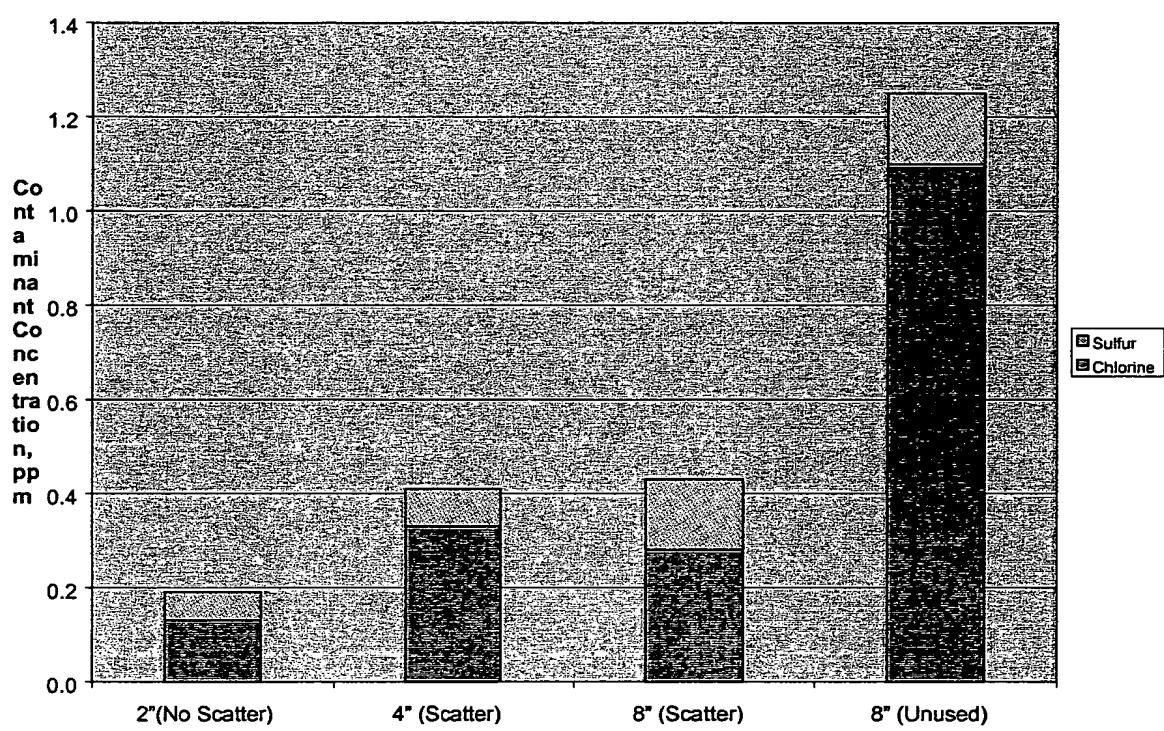
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FIG. 13



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FIG. 14



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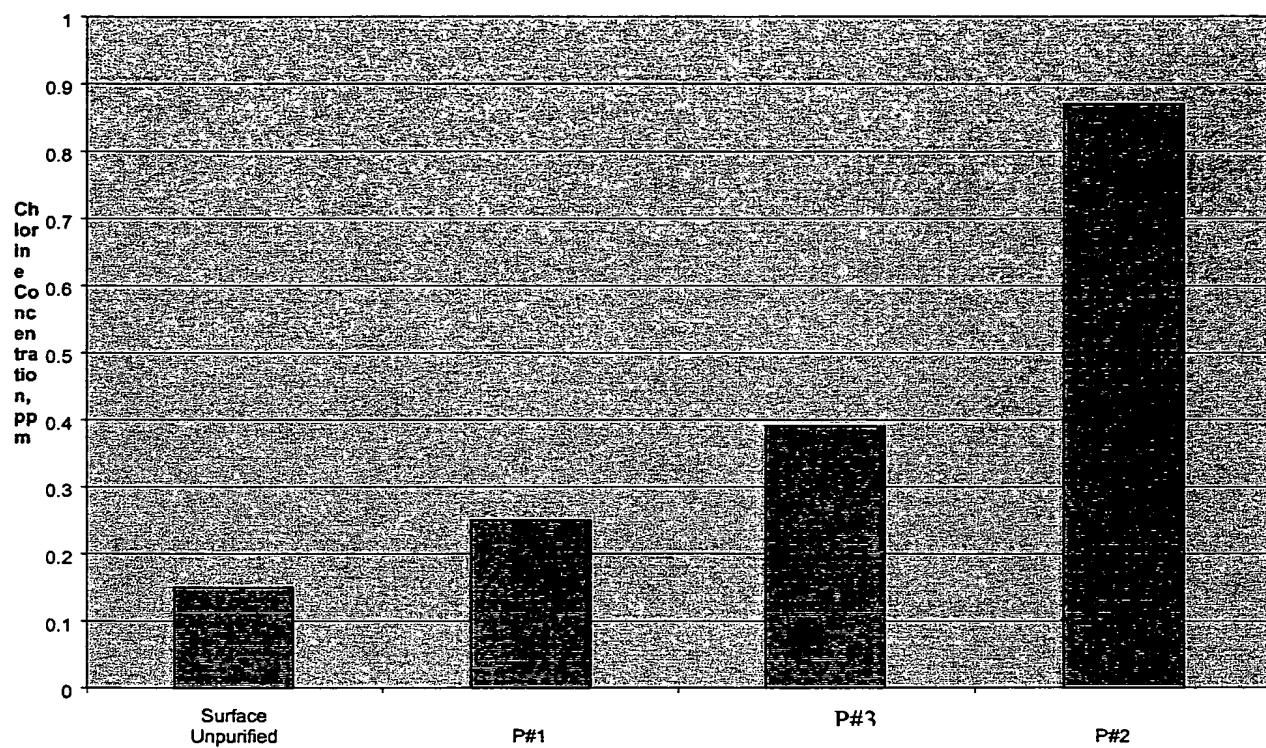


FIG. 15

Fig. 16

